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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/721,480	11/25/2003	Kyu-Mann Lee	5649-1218	5987	
7:	590 11/18/2005		EXAMINER		
Robert N. Crouse			NGO, NGAN V		
Myers Bigel Sibley & Sajovec Post Office Box 37428			ART UNIT	PAPER NUMBER	
Raleigh, NC 2	27627		2818		
			DATE MAILED: 11/18/200	5	

Please find below and/or attached an Office communication concerning this application or proceeding.

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		Application No.	Applicant(s)	- ++
Office Action Summary		10/721,480	LEE ET AL.	
		Examiner	Art Unit .	
	·	Ngan Ngo	2818	
Period fo	The MAILING DATE of this communication app or Reply	ears on the cover sheet with the c	orrespondence address -	•
WHIC - Exte after - If NC - Failu Any	CORTENED STATUTORY PERIOD FOR REPLY CHEVER IS LONGER, FROM THE MAILING DATES IN THE MAILING THE	ATE OF THIS COMMUNICATION 36(a). In no event, however, may a reply be tin vill apply and will expire SIX (6) MONTHS from , cause the application to become ABANDONE	N. nely filed the mailing date of this communica D (35 U.S.C. § 133).	
Status	·			•
2a)	Responsive to communication(s) filed on This action is FINAL. 2b) This Since this application is in condition for allowar closed in accordance with the practice under E	action is non-final.		is .
	closed in accordance with the practice under L	x parte Quayle, 1955 C.D. 11, 40)3 O.G. 213.	
Disposit	ion of Claims			
5) 6) 7)	Claim(s) 1-25 is/are pending in the application. 4a) Of the above claim(s) is/are withdraw Claim(s) is/are allowed. Claim(s) is/are rejected. Claim(s) is/are objected to. Claim(s) 1-25 are subject to restriction and/or expressions.	vn from consideration.		•
Applicat	ion Papers	4		
9) 10)	The specification is objected to by the Examine The drawing(s) filed on is/are: a) access Applicant may not request that any objection to the Replacement drawing sheet(s) including the correction The oath or declaration is objected to by the Examine	epted or b) objected to by the bed drawing(s) be held in abeyance. See ion is required if the drawing(s) is object.	e 37 CFR 1.85(a). jected to. See 37 CFR 1.12	
Priority (under 35 U.S.C. § 119	•		
a)	Acknowledgment is made of a claim for foreign All b) Some * c) None of: 1. Certified copies of the priority documents 2. Certified copies of the priority documents 3. Copies of the certified copies of the prior application from the International Bureau See the attached detailed Office action for a list	s have been received. s have been received in Applicati rity documents have been receive u (PCT Rule 17.2(a)).	ion No ed in this National Stage	
2) Notice 3) Information	nt(s) ce of References Cited (PTO-892) ce of Draftsperson's Patent Drawing Review (PTO-948) rmation Disclosure Statement(s) (PTO-1449 or PTO/SB/08) er No(s)/Mail Date	4) Interview Summary Paper No(s)/Mail D 5) Notice of Informal F 6) Other:		

Restriction to one of the following inventions is required under 35 U.S.C. § 121:

I. Claims 1-10, drawn to a semiconductor device, classified in Class 257, subclass 295.

II. Claims 11-25, drawn to a process for making a semiconductor device, classified in Class 438, subclass 1+.

The inventions are distinct, each from the other because of the following reasons:

Inventions II and I are related as process of making and product made. The inventions are distinct if either or both of the following can be shown: (1) that the process as claimed can be used to make other and materially different product or (2) that the product as claimed can be made by another and materially different process (M.P.E.P. § 806.05(f)). In the instant case unpatentability of the group I invention would not necessarily imply unpatentability of the group II invention, since the device of the group I invention could be made by processes materially different than those of the group II invention. For example, selectively forming the interlayer dielectric layer and the protection adhesion layer on the subtrate to provide the contact hole; therefore the step of "forming a contact hole" after the formation of the interlayer dielectric layer and the protection adhesion layer is not needed.

Because these inventions are distinct for the reasons given above and, as shown by the above different classifications, the fields of search are not co-extensive and separate examination would be required, restriction for examination purposes as indicated is proper.

Applicant is advised that the response to this requirement to be complete must include an election of the invention to be examined even though the requirement be traversed.

Art Unit: 2818

Any inquiry concerning this communication should be directed to Examiner Ngan Ngo at telephone number (571) 272-1711. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Mm J NY

Ngan Van Ngo Primary Examinar

Ngan Ngo

November 16, 2005